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Correction: Synthesis of heteroleptic [Sr(ddemap)(tmhd)]₂ and its use in atomic layer deposition of low carbon SrO thin films

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The authors regret that the name of one of the authors (Taek-Mo Chung) was shown incorrectly in the original article. The corrected author list is as shown above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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